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Correction: Seaming the interfaces between topologically distinct metal–organic frameworks using random copolymer glues

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rsc.li/nanoscaleCorrection for 'Seaming the interfaces between topologically distinct metal–organic frameworks using random copolymer glues' by Fang Wang *et al.*, *Nanoscale*, 2019, **11**, 2121–2125, DOI: 10.1039/C8NR09777A.

The authors regret the omission of the affiliations of one of the authors, Fang Wang, from the original manuscript. The corrected list of affiliations for this paper is as shown above.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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